

Supporting Information for

**Polyvinylpyrrolidone-enhanced perovskite films for efficient direct X-ray
detection**

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1. Experiments

1.1. Chemicals and Reagents

Lead iodide (PbI_2 , 99.999%), Methylammonium iodide (MAI, 99.999%), (6,6)-Phenyl C_{61} Butyric Acid Methyl Ester (PC_{61}BM) and SnO_2 (12wt% in H_2O) were purchased from Xi'an Yuri solar Co., Ltd. Polyvinylpyrrolidone (PVP, $M_w \sim 55000$) was purchased from Sigma-Aldrich. Chlorobenzene (CB, 99.8%), Dimethylformamide (DMF, 99.8%) and Dimethylsulfoxide (DMSO, 99.8%) were purchased from Thermo scientific. All commercial materials were used without any further purification.

1.2. Detector Fabrication

ITO glasses (2.0×2.0 cm) were initially cleaned with detergent, ultra-pure water, acetone, and isopropyl alcohol using ultrasonic, and then dried. Then the ITO glasses were subjected to UV ozone treatment for 15 minutes. SnO_2 colloidal dispersion was mixed with ultra-pure water in a volume ratio of 1:3. Then, the SnO_2 solution was filtered through a $0.45 \mu\text{m}$ filter and spin coated on the ITO substrates at 3000 rpm for 30 s, followed by annealing at 120°C for 10 minutes and 150°C for 20 minutes. The perovskite precursor solution was prepared by adding PbI_2 (2.5 M) and MAI (2.5 M) in the mixture of a DMF/ DMSO (9:1 by volume). Additionally, PVP was added to the solution as an additive at concentrations of 0 mg mL^{-1} , 3 mg mL^{-1} and 5 mg mL^{-1} . Following stirring at 60°C for 10 hours. The SnO_2 -covered ITO substrate was treated with UV ozone for 15 minutes, and then heat it at 100°C . The $70 \mu\text{L}$ of perovskite precursor solution was dropped on the substrate hot plate, with a distance of $500 \mu\text{m}$ between the blade and the substrate. Finally, the blade was pushed at a speed of $10 \text{ millimeters s}^{-1}$ to evenly cover the solution on the substrate. After coating the blade, the resulting film was annealed at 120°C for 10 hours. Finally, a 100 nm silver electrode was ultimately deposited on the surface of the perovskite film by thermal evaporation method. For electron-only devices, a PCBM layer was fabricated on the perovskite layer. A 20 mg mL^{-1} PCBM solution was prepared using CB as the solvent and stirred at 70°C for 2 hours. Subsequently, the PCBM solution ($70 \mu\text{L}$) was spin-coated onto the perovskite layer at 1500 rpm for 30 seconds, followed by annealing at 100°C for 5 minutes.

1.3. Materials Characterizations

Photoluminescence (PL) emission spectra and PL decay curves (TRPL) were measured on the FLS980 spectrometer (Edinburgh) equipped with both continuous (450 W) and pulsed xenon lamps. A Rigaku MiniFlex-II X-ray diffractometer with $\text{Cu-K}\alpha$ radiation ($\lambda = 1.54184 \text{ \AA}$) was used to record X-ray diffraction (XRD) patterns, with the films were placed at a scanning angle of 10° to 50° and a scanning speed of $10^\circ \text{ min}^{-1}$. MAI and PVP (1:1 molar ratio) were dissolved in DMSO to prepare the experimental solution, and the same amount of PVP dissolved in DMSO to prepare the control solution. These solutions were analyzed by IS50R FTIR spectrometer to record Fourier transform infrared spectroscopy (FTIR). Field emission scanning electron microscopy (SEM, Nova Nano SEM 230 system) was used to detect the morphology of the surface cross-section of the film. X-ray photoelectron spectroscopy (XPS) was used to study the surface chemical state of the materials. The experiments were performed using an ESCALABQXI photoelectron spectrometer equipped with a monochromatic Al-K α (1486.6 eV) X-ray source. During the analysis process, we corrected the electrostatic effects of all recorded peaks by calibrating the CAC component of the C 1s

peak to 284.8 eV. The liquid state ^1H nuclear magnetic resonance (^1H NMR) spectra was measured by a nuclear magnetic resonance spectrometer (BRUKERAV600).

1.4. Detector Performance Measurement

Tungsten anode X-ray tube (Moxtek MAGPRO) is used as a radiation source. The X-ray source operates at an acceleration voltage of 10 kV. The dose rate is controlled by varying the X-ray tube current and calibrated it using a Radcal ion chamber (model: 10 X 6-180) dosimeter. The current-voltage and X-ray response curves of the device are recorded at room temperature by using a customized X-ray detector electrical performance testing system. All X-ray response characterizations were performed in dark air to minimize interference from ambient light response.

2. Other Related Figures

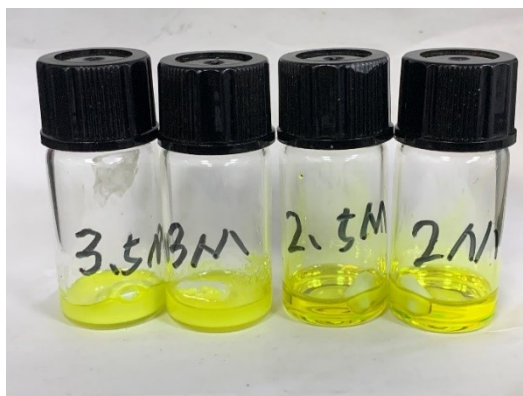


Fig. S1. A comparative dissolution diagram of precursor solutions with concentrations of 2.0 M, 2.5 M, 3.0 M, and 3.5 M, obtained after stirring at 60 °C for 12 hours.

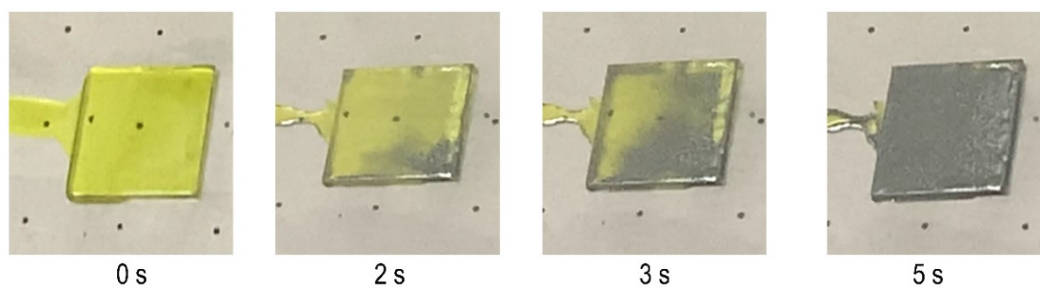


Fig. S2. Photographs of the change process of perovskite precursor solution on the substrate after blade coating under the ambient conditions (60%-70% humidity, 25 °C).

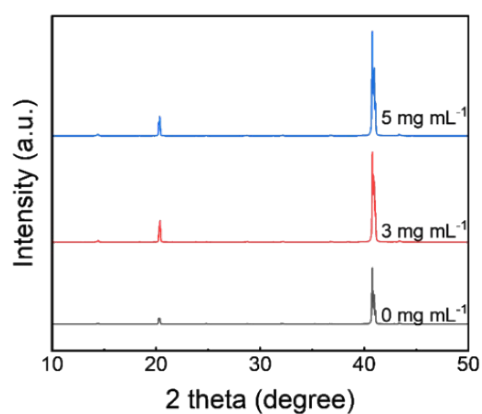


Fig. S3. XRD patterns of perovskite films with different concentrations of PVP.

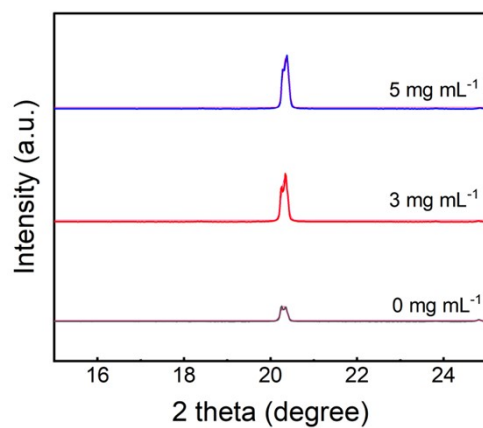


Fig. S4. Gaussian fitting plots of the maximum full-width at half-maximum (FWHM) for the (200) diffraction peaks of the three perovskite films within the diffraction angle range of 15° to 25°.

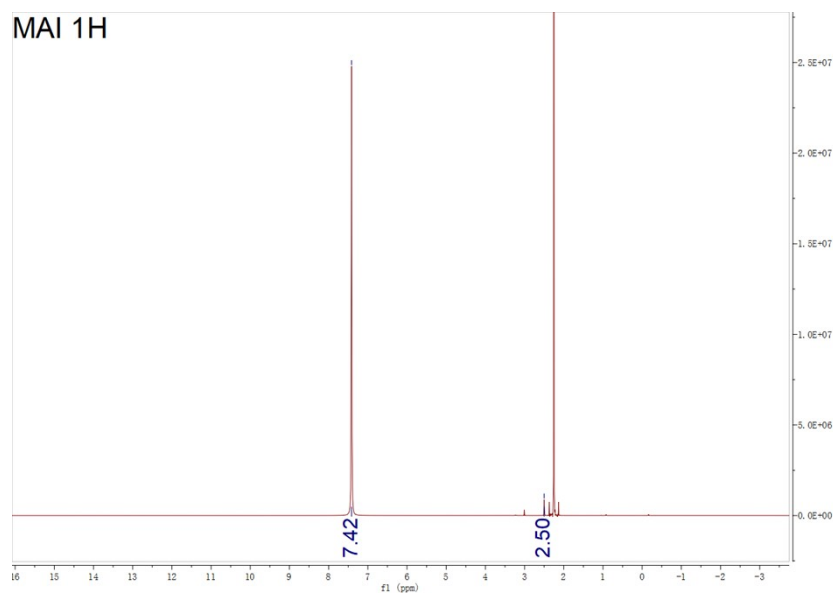


Fig. S5. ^1H NMR full spectrum of MAI in DMSO- d_6 .

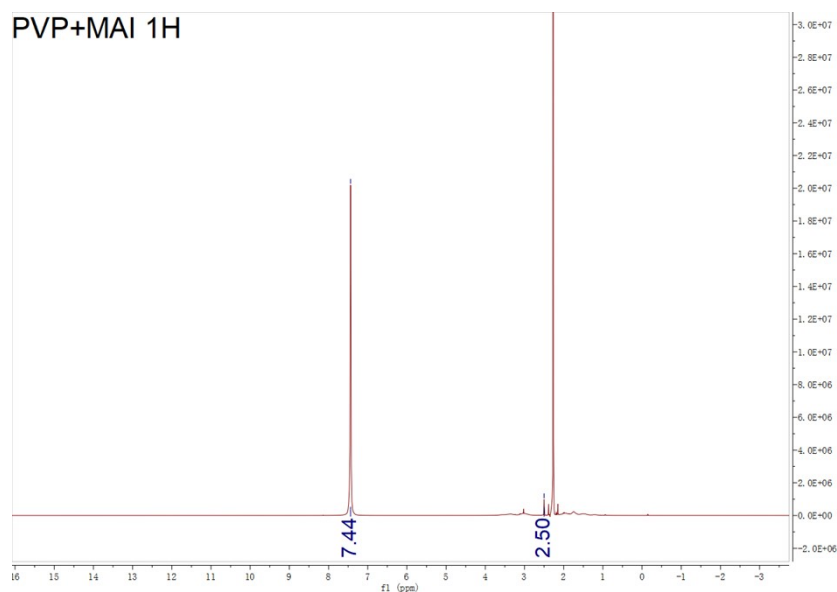


Fig. S6. ^1H NMR full spectrum of PVP+MAI at a molar ratio of 1:1 in DMSO- d_6 .

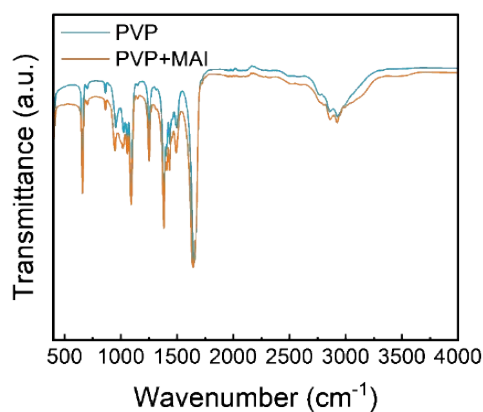


Fig. S7. FTIR full spectra of MAI, PVP+MAI prepared by mixing PVP with MAI in a molar ratio of 1:1.

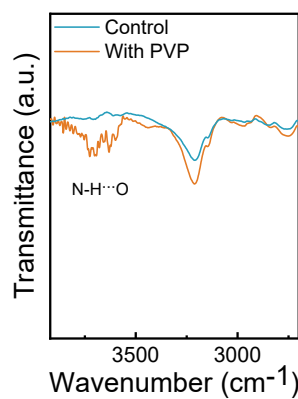


Fig. S8. FTIR spectra of control film and PVP-optimized film, a distinct peak at 3630 cm^{-1} indicated the stretching vibration peak of $\text{N-H}\cdots\text{O}$.

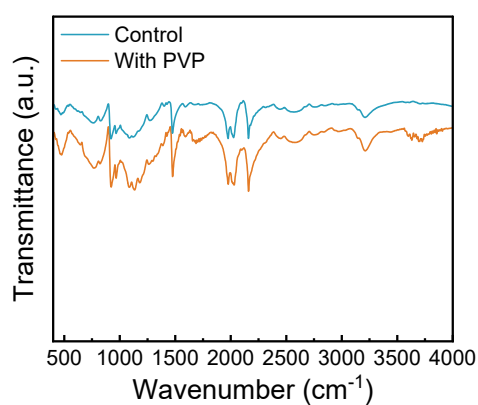


Fig. S9. FTIR full spectra of control film and PVP-optimized film.

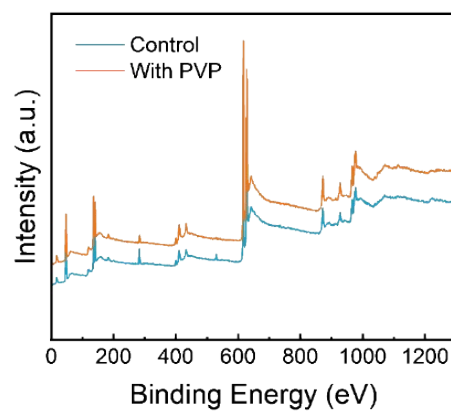


Fig. S10. XPS full spectra of control perovskite film and perovskite film with PVP.

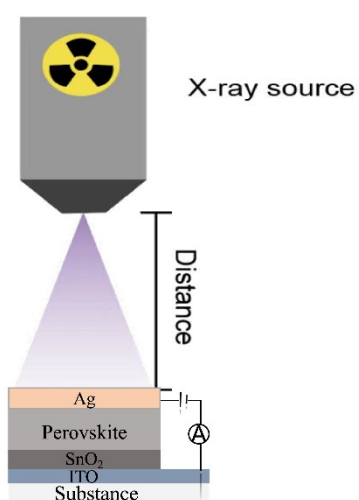


Fig. S11. Schematic diagram of device setup for X-ray performance test.

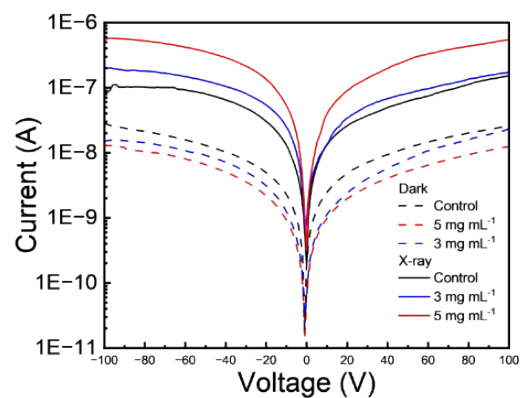


Fig. S12. Current voltage (J - V) curves of the detectors based on the films with different concentrations of PVP under dark condition and X-ray irradiation, the dose rate is $11470 \mu\text{Gy}_{\text{air}} \text{s}^{-1}$.

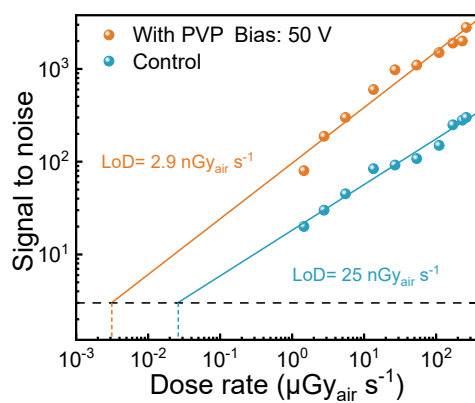


Fig. S13. Signal-to-noise ratio of the two detectors under bias voltages of 50 V and 10 keV X-ray energy. The dashed line means a SNR value of 3.

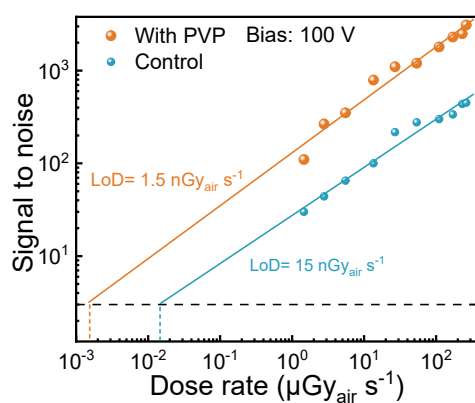


Fig. S14. Signal-to-noise ratio of the two detectors under bias voltages of 100 V and 10 keV X-ray energy. The dashed line means a SNR value of 3.

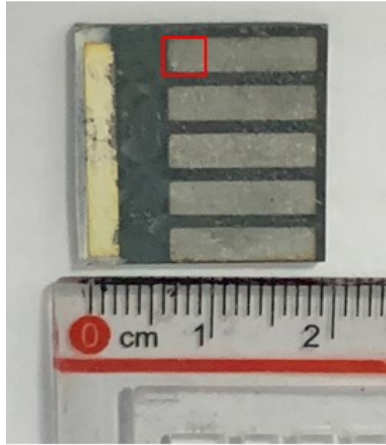


Fig. S15. Photograph of the complete device with an area of 2.0×2.0 cm, where the red box indicated the active device regions, totaling five active device regions.

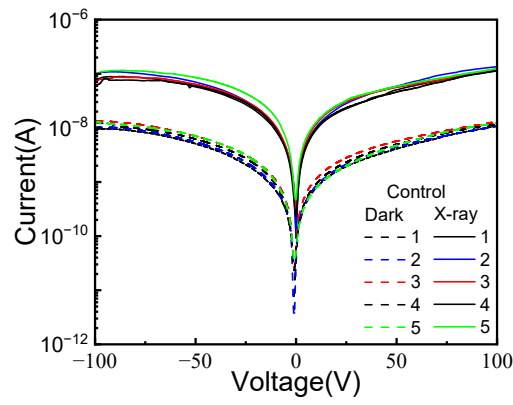


Fig. S16. J - V curves of the control detector under dark and X-ray radiation.

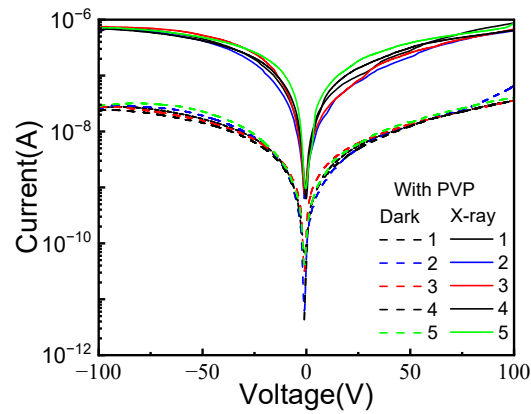


Fig. S17. J - V curves of the PVP-optimized detector under dark and X-ray radiation.

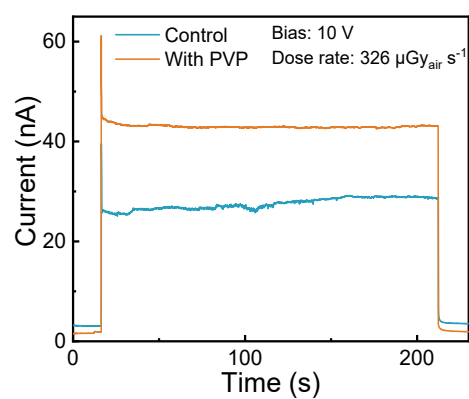


Fig. S18. Radiation stability of the two devices under a bias voltage of 10 V and X-ray energy of 10 keV.

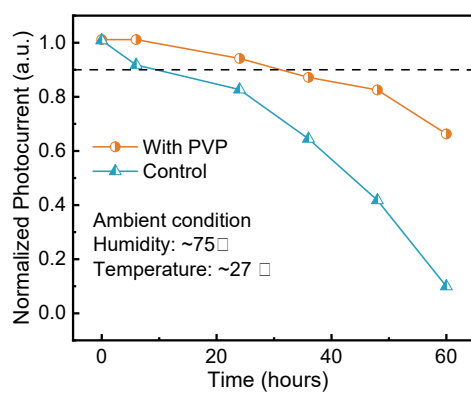


Fig. S19. The trend of X-ray current intensity of the device decreasing with storage time in ambient environment.

Supplementary Note 1: Estimation of the upper sensitivity limit under 10 keV X-rays.

The upper theoretical limit of the specific surface sensitivity $S_{\max}$ ($\mu\text{C Gy}^{-1} \text{cm}^{-2}$) of a detector can be calculated by the following formula:

$$S_{\max} = \frac{e\mu_p\rho d}{\mu E_i}$$

Here, e is the electron charge (C), ρ is the density of the active layer (g cm^{-3}), d is the thickness of the active layer (cm), μ_p and μ ($\text{cm}^2 \text{g}^{-1}$) are respectively the mass attenuation coefficients of the active layer material and dry air at the average photon energy. E_i is the generation energy of electron-hole pairs, which can be expressed as $E_i = 2E_g + 1.43 = 4.43$ eV (where E_g is the band gap energy).

In the case of the device introduced in this work, the active material is a MAPbI_3 film with thickness $d = 1.9 \times 10^{-3}$ cm. We assume the density of the MAPbI_3 active layer is $= 4.1 \text{ g cm}^{-3}$, whereas μ_p and μ are obtained by using the XCOM software provided by NIST (National Institute of Standards and Technology). Fig S20 and Fig S21 reports the mass attenuation coefficient of MAPbI_3 and dry air in the 1 keV-10 MeV energy range.

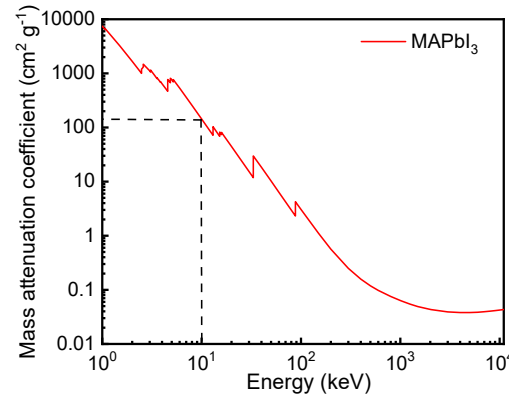


Fig. S20. Mass attenuation coefficient of MAPbI_3 in the 1 keV-10 MeV energy range.

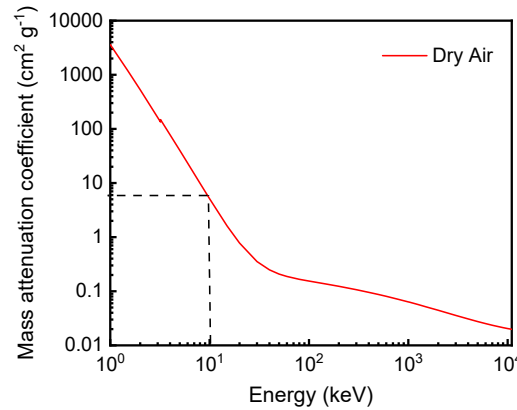


Fig. S21. Mass attenuation coefficient of dry air in the 1 keV-10 MeV energy range.

By considering a photon energy is 10 keV, the mass attenuation coefficient is $\mu_p = 139.96 \text{ cm}^2 \text{g}^{-1}$. At the same photon energy (10 keV), the mass attenuation coefficient of dry air is $\mu = 6.06 \text{ cm}^2 \text{g}^{-1}$. Finally, being the bandgap energy $E_g = 1.5$ eV, the estimated electron-hole pair creation energy is $E_i = 4.43$ eV.

By substituting all the numerical values into the $S_{\max}$ equation we obtain: $S_{\max} = 40.61 \mu\text{C Gy}^{-1} \text{cm}^{-2}$

3. Other Related Tables

Table S1. The maximum full-width at half - maximum (FWHM) of the (200) diffraction peak of the three perovskite films in the diffraction angle range of 15°-25° was obtained through gaussian fitting.

Model	Gauss		
Equation	$y=y_0 + (A/(w*\sqrt{\pi/2}))*\exp(-2*((x-xc)/w)^2)$		
Sample	0 mg mL ⁻¹	3 mg mL ⁻¹	5 mg mL ⁻¹
y0	1504.98808	2904.22154	2738.93775
xc	20.30719	20.32328	20.3504
w	0.14349	0.13961	0.13508
A	3625.64454	10485.79222	12100.62541
sigma	0.07174	0.06981	0.06754
FWHM(β)	0.16894	0.16438	0.15904
Height	20161.10268	59926.99632	71476.66866
Reduced Chi-Sqr	1.41540E6	1.21155E7	9.28510E6
Adj. R-Square	0.95177	0.95153	0.9743

Table S2. Detailed fitting parameters of the control MAPbI₃ film and MAPbI₃ film with PVP preparing on glass substrate, obtained from the TRPL measurement.

Sample	τ ₁ [μs]	B ₁	τ ₂ [μs]	B ₂	τ _{ave} [μs]
Control	0.77	0.82	9.51	0.03	3.49
With PVP	0.94	0.93	13.43	0.04	5.69

TRPL can be well fitted by the following formulas with biexponential components:

$$f(t) = A + B_1 \exp\left(\frac{-t}{\tau_1}\right) + B_2 \exp\left(\frac{-t}{\tau_2}\right)$$

$$\tau_{ave} = \frac{B_1 \tau_1^2 + B_2 \tau_2^2}{B_1 \tau_1 + B_2 \tau_2}$$

where A is a constant for the baseline offset, B_1 and B_2 are the relative amplitudes, τ_1 and τ_2 are the carrier lifetimes for the fast and slow recombination, respectively. τ_{ave} is average carrier lifetime.

Table S3. X-ray detection performance of this work in comparison with previous reports.

Material	Sensitivity (μC Gy _{air} ⁻¹ cm ⁻²)	LoD (nGy _{air} s ⁻¹)	Bias voltage(V)	Thicknees (μm)	Reference
PVP/MAPbI ₃	2.6×10 ³	11	100	19	This work
PEA ₂ PbBr ₄	2998	0.79	100	1000	S1
Cs ₃ Bi ₂ I ₉	1652.3	130	60	1200	S2
Cs ₂ AgBiBr ₆	105	59.7	50	2000	S3
(F-PEA) ₂ PbI ₄	3402	23	266	2000	S4

Reference

- S1. Su X, Wang R, Yu H. Coatings, 2024, **14**, 633.
- S2. Wang J, Zhang J, Zhou Y. Nature communications, 2020, **11**, 177.
- S3. Pan W, Wu H, Luo J. Nature photonics, 2017, **11**, 726-732.
- S4. Li H, Song J, Pan W. Advanced Materials, 2020, **32**, 2003790.